

	Type	L #	Hits	Search Text	DBs
1	BRS	L1	1094	(si-ge) or (ge-si)	US-PGPUB; USPAT
2	BRS	L2	82	1 near2 epitaxial	US-PGPUB; USPAT
3	BRS	L3	20	2 same channel	US-PGPUB; USPAT
4	BRS	L4	4379	tensile adj2 strain	US-PGPUB; USPAT
5	BRS	L5	121	4 near3 biaxial	US-PGPUB; USPAT
6	BRS	L6	12	5 same nmos	US-PGPUB; USPAT
7	BRS	L8	1121	carbon near3 doped near3 silicon	US-PGPUB; USPAT
8	BRS	L10	327	8 near3 (layer or film)	US-PGPUB; USPAT
9	BRS	L11	18	channel same 10	US-PGPUB; USPAT
10	BRS	L12	81	channel and 10	US-PGPUB; USPAT
11	BRS	L13	11	(tensile adj2 strain) and 12	US-PGPUB; USPAT

	Type	L #	Hits	Search Text	DBs
12	BRS	L14	173	carbon near3 doped near3 silicon	USOCR; EPO; JPO; DERWE NT; IBM_TD B
13	BRS	L15	7	channel same 14	USOCR; EPO; JPO; DERWE NT; IBM_TD B
14	BRS	L16	9	(US-20020063292-\$ or US-20040256639-\$ or US-20050009263-\$ or US-20050035369-\$ or US-20050054168-\$ or US-20050116360-\$ or US-20050164477-\$ or US-20040256647-\$).did. or (US-6921913-\$).did.	US- PGPUB; USPAT
15	BRS	L17	2	8 and 16	US- PGPUB; USPAT
16	BRS	L18	2	17 and (tensile adj2 strain)	US- PGPUB; USPAT
17	BRS	L19	992	channel same SiC	US- PGPUB; USPAT

	Type	L #	Hits	Search Text	DBs
18	BRS	L20	41	19 and (tensile adj2 strain)	US-PGPUB; USPAT
19	BRS	L21	8	19 same (tensile adj2 strain)	US-PGPUB; USPAT